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Contributions Welcome

Readers are encouraged to submit news items concerning the Society and its members. Please send your ideas/articles directly to either the Editor-in-Chief or appropriate Editor. All contact information is listed on the back cover page. Whenever possible, e-mail is the preferred form of submission.

Newsletter Deadlines

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2000 International Symposium on Power Semiconductor Devices and ICs (ISPSD)

The 12th International Symposium on Power Semiconductor Devices and ICs (ISPSD), sponsored by the IEEE Electron Devices Society, the Institute of Electrical Engineers of Japan and the European Power Electronics Association, will be held at the Pierre Baudis Congress Centre, Toulouse, France from May 22 to 25, 2000.

The purpose of the Symposium is to provide a forum for presentations and discussions on power semiconductor devices and ICs. This forum has grown in twelve years to become the largest in the field, and regularly draws the foremost technical contributors from industry and academia world-wide. ISPSD is held each year in a different location, rotating between Europe, Asia and North America. A large number of high quality contributed and invited papers will cover a broad range of state of the art topics over the three and a half days of the Symposium. Most of the conference will consist of contributed oral presentations representing the most current work in the field. An extended poster session will also be included to provide an expanded range of coverage on special topics of interest and provide an opportunity for close interaction with authors as they discuss their work. The topics that will be covered are likely to include the following:

(continued on page 3)

Your Comments Solicited

Your comments are most welcome. Please write directly to the Editor-in-Chief of the Newsletter at the address given on the back cover page.
The fourth annual joint IEEE Divisions I and IV Region 8 Chapters Meeting was held on 12 September, 1999 in Leuven, Belgium in conjunction with the European Solid-State Device Research Conference (ESSDERC). This Division level meeting evolved three years ago from the chapters meeting first coordinated in 1994 by Mike Adler and Rolf Jansen for the Electron Devices and Microwave Theory and Techniques societies. The goal of the meeting was increased chapter formation and support for Region 8, particularly Eastern Europe and the Former Soviet Union. At this year’s meeting, there were 60 attendees representing 9 societies and 43 chapters from 25 different countries in Region 8. EDS had 26 of its 35 Region 8 Chapters attend this year’s event.

This joint Division meeting was co-chaired by the Division I Director, Mike Lightner, and the Division IV Director, Bill Gjerston. Division I includes the CAS, CPMT, ED, LEO and SSC societies, while the AP, BT, CE, EMC, MAG, MT and NPS societies comprise Division IV. The idea of a combined Division I and IV Chapters Meeting was a fairly natural occurrence, since many chapters in Region 8 are joint ones involving the two divisions. Of the 43 chapters present, 25 are joint chapters, with 18 involving societies in both divisions.

The meeting began at 8:30 a.m. with a welcome and review of the agenda by Mike Lightner, followed by self-introductions by all participants. Bill Gjerston then gave his welcome, while Cor Claey, the ESSDERC Organizing Committee Chair, continued with a welcome from ESSDERC and provided information concerning the conference.

The Region 8 Director, Rolf Remshardt, followed with some Region 8 statistics as well as information concerning the Region 8 Help Desk and Voluntary Contribution Fund. Antonio Bastos, the RAB/ TAB Section/ Chapter Support Chair, outlined the responsibilities and strategic objectives of his committee. The Benelux Section Chair, Cor Claey, welcomed the attendees to Leuven. Region 8 membership development and chapter co-ordination activities and plans were presented by the Region 8 Membership Development Chair, Peer Martin Larsen, and Region 8 Chapter Coordination Chair, Tony Davies, respectively.

(continued on page 6)
Upcoming Technical Meetings

ISPSD (continued from page 1)

- Materials and Processes: Crystal Growth, Doping, Lifetime Control, Passivation, Thick Film Metallization, Semiconductor Materials, Characterization
- CAD and Simulation: Process, Device, Circuit, Thermal, Electrothermal, Electromechanical Aspects
- Devices: Device Physics, Modeling, Characterization, Reliability, Fast Switching, High Frequency Power, Discrete and Integrated Power
- Monolithic and Hybrid Power Integration: Technology, Isolation Techniques, Design, Smart Power IC's, High Voltage IC's, Hybrid Modules
- Packaging: Thermal Management, Novel Techniques, Stress and Reliability, Electrothermal Cycling
- Applications: all discrete and integrated power areas, device design and optimization for specific application

A proceedings and a CD ROM, including all accepted contributions, will be published and handed out at the conference. The Symposium will also include several special events, such as a reception in the famous “Salle des Illustres” located inside the Capitol building and a banquet dinner in a famous French lifestyle place.

Toulouse is situated in south-west France, 680 km from Paris, between the Atlantic Ocean and the Mediterranean Sea. Toulouse is the Capital of the Midi-Pyrénées Region, the largest French province. With a population of 700,000, Toulouse is also nicknamed “The Pink Town” due to its numerous old pink brick walls, but it is also a green town with many gardens, pretty fountains and even barges going trough the “Canal du Midi”. Already bustling 2,000 years ago, the city boasts a rare architectural and artistic heritage including in particular the Basilica Saint-Sernin (11th century), Saint-Etienne’s Cathedral (12th century), the Church and Cloister of the Jacobins (13th century), the Capitol (18th century) and the Augustins Museum (18th century). The quality lifestyle, varied gastronomic dishes, chanting southern-accent, etc., all make Toulouse a pleasant town to live and work in.

Toulouse is the European Capital of aeronautics and space, and a leading centre in industry, technology and research. With a wealth of educational institutions that include universities and several research laboratories covering all spheres of knowledge, Toulouse has the second largest university in France and ranks among the top university cities in Europe. Toulouse University was founded in 1229, so it has had time to form its own personality and its own specific characteristics. Today, over 115,000 students attend courses in its three major faculties, its institutes and ‘grandes Écoles’.

Don’t worry about the weather: the climate in Toulouse is usually temperate around the time of the conference. However, there is no special arrangement about it, as it is outside the competence of the organizing committee!

For further information on the conference please visit the conference website at http://www.laas.fr/ISPSD2000. On behalf of the Conference Committee, we would like to invite you to attend ISPSD’2000 and are looking forward to welcoming you in Toulouse.

Georges Charitat
LAAS-CNRS
Toulouse, France

2000 International Conference on Microelectronic Test Structures (ICMTS)

The 2000 IEEE International Conference on Microelectronic Test Structures (ICMTS) will convene for the final time in the twentieth century, March 14-16, 2000, when it returns to the Doubletree Hotel in Monterey, California. It will be preceded by a one day Tutorial Short Course on microelectronic test structures on March 13, 2000.

The ICMTS is the preeminent meeting of test structure creators and consumers. It provides an annual forum for discussing the latest innovations in microelectronic test structure design and characterization. Original papers presenting new developments in silicon and gallium arsenide microelectronic test structure research, implementation, and applications as well as test structures aimed at new materials and devices will be presented. Topics include test structures for use in the following areas:

- Material and process characterization
- Replicated feature metrology
- Device and circuit modeling
- Wafer fabrication process control
- Reliability and product failure analysis
- New sensors and devices
- Statistical data analysis

The conference format provides for a single program track (without parallel sessions). This allows all participants to attend all presentations. A majority of the presentations are oral. The oral presentation format provides traditional fifteen-minute presentations with ample time for questions and answers both immediately following presentations and informally during coffee breaks. In addition, a poster session allows less formal and more in-depth interaction with poster authors. Poster authors also provide brief oral presentations to provoke interest in and attendance at their posters.

Both poster presentations and oral presentations are eligible for the ICMTS Best Paper Award. This award is determined...
ICMTS  (continued from page 3)

dined by the Technical Committee at the conference and awarded the following year. The ICMTS 1999 Best Paper Award for “A Thermal van der Pauw Test Structure” by O. Paul, L. Plattner, and H. Baltes will be presented during ICMTS 2000. In addition, in the past selections of the most appropriate ICMTS papers have been included in a special section of the IEEE Transactions on Semiconductor Manufacturing.

The Tutorial Short Course, which immediately precedes the conference, offers a blend of tutorial and advanced topics. Test structure creation and characterization basics are always included. Furthermore, the ICMTS 2000 will include tutorials on test structures for SOI characterization as well as yield modeling.

In addition to the technical presentations, ICMTS 2000 will, once again, include an equipment exhibition. Vendors providing measurement equipment, data analysis software, and other test structure related wares will have their latest versions available for evaluation.

While still a small conference, ICMTS attendance has been steadily increasing. The compact size of the conference is conducive to both social and professional interaction. Many first-time attendees are enthusiastic to interact with so many others working in the field of test chips and test structures. Once discovering ICMTS, they return regularly.

To encourage international participation, the ICMTS rotates between North America, Asia, and Europe. The 1998 and 1999 meetings were held in Kanazawa, Japan and Gothenburg, Sweden, respectively. Past conferences have attracted papers from nearly every continent, guaranteeing an international flavor. Submissions include a broad cross-section of industry, university, and government-sponsored work.

Monterey, California provides an ideal location for ICMTS 2000. The Monterey Peninsula has been called the perfect meeting of land, sea and sky. This beautiful seaside community provides the charm of small town America and an endless variety of recreational and cultural activities. Monterey's rich history, the saga of California's Mission Trail, historic Fisherman's Wharf and Cannery Row, the world's best aquarium, a unique variety of shops and galleries and a spectacular assortment of parks and natural areas combine to provide a truly unrivaled back drop for ICMTS 2000.

For additional information regarding the technical sessions, please contact ICMTS 2000 Technical Chair, Christopher Hess, PDF Solutions, 333 W. San Carlos Street, Suite 700, San Jose, CA 95110, USA; TEL: 1-408-938-4636; FAX: 1-408-280-7915; EMAIL: hess@pdf.com.

For information regarding the tutorial short course, please contact ICMTS 2000 Tutorial Chair Ellen Piccioli, Compaq Computer Corporation, 334 South Street, Shrewsbury, MA 01545, USA; TEL: 1-508-841-2856; FAX: 1-508-841-3576; EMAIL: ellen.piccioli@compaq.com.

For information regarding the equipment exhibition, please contact ICMTS 2000 Equipment Exhibition Chairperson, James Reedholm, Reedholm Instruments, Four Sierra Way, Georgetown, TX 78626, USA; TEL: 1-512-869-1935; FAX: 1-512-869-0992; EMAIL: jim@reedholm.com.

In addition, general information may be found at our website at http://www.ee.ed.ac.uk/ICMTS/.

Lawrence A. Bair
Compaq Computer Corporation
Shrewsbury, MA

2000 International Vacuum Electronics Conference (IVEC)

With an agenda that includes virtually all aspects of vacuum electron devices and their applications, the First International Vacuum Electronics Conference (IVEC) will meet at the Doubletree Hotel in Monterey, CA, May 2-4, 2000. The conference is being organized by the Technical Committee on Vacuum Devices of the IEEE Electron Devices Society (EDS). IVEC is being sponsored by EDS, and has drawn numerous technical co-sponsors. IVEC will welcome contributions from the many sub-disciplines of vacuum electronics, hoping to stimulate the growth of technology and emphasize enhanced support for applications.

The format planned for IVEC will begin with a half day Plenary Session followed by two days with three parallel Oral Sessions and a half day for a Poster Session. Abstracts for IVEC 2000 should be submitted electronically (Microsoft Word preferred) to Ralph Nadell at Rnadell@newyork.palisades.org by January 14, 2000. Further details regarding IVEC 2000 are available on the web at www.ewh.ieee.org/ soc/ eds/ ivec, from IVEC General Chair, James A. Dayton, Jr., at James.Dayton@hughes.com or from Publicity Chair, Carol L. Kory at Carol.L.Kory@grc.nasa.gov.

IVEC will meet annually, rotating between the USA, Europe and Asia. In planning IVEC, care has been taken not simply to add additional conference dates to an already crowded calendar. While IVEC is new, the vacuum electronics community has been meeting in Monterey every two years since 1978 at the Microwave Power Tube Conference, known informally as the Monterey Conference. Sponsored by the US DoD Advisory Group on Electron Devices, attendance at the Monterey Conference had been by invitation and restricted to US citizens and permanent residents. The Monterey Conference has become the US leg of IVEC and will now be open to participation, regardless of nationality.

In Europe in April 2001, the Space TWTA Workshop, sponsored by the European Space Agency (ESA), will be expanded in scope to become the European leg of IVEC. The ESA workshops have previously been held in 1989, 1991, 1994 and 1997 and have always been open to all nationalities. IVEC will return to the USA in 2002 and will meet in Asia in 2003.

The principal subject categories for IVEC 2000 are Devices, Vacuum Microelectronics, Systems and Subsystems, Technologies, and Applications; for complete details, see
the conference announcement or refer to the website. IVEC will seek papers on a wide range of Vacuum Devices, including traveling wave tubes, crossed field devices, klystrons, inductive output tubes, fast wave devices, free electron lasers, pulse compression devices, high pulsed power devices, plasma filled amplifiers, triodes, tetrodes, pentodes and switches. In the area of Vacuum Microelectronics, IVEC is seeking papers on displays, sensors, field emitter arrays and microwave devices. Under Systems and Subsystems, IVEC is including microwave power modules, electronic power conditioners, linearizers, device integration, reliability and component parts (guns, collectors etc.). Under the heading of Technologies, IVEC is seeking papers on computer modeling, materials, electron emission, RF breakdown, linearity, intermodulation, noise, measurement techniques, miniaturization and thermal control. It is intended to intersperse papers on all aspects of the applications of vacuum electronics throughout the conference.

IVEC had its origins in the Fall of 1997 when EDS organized the Technical Committee on Vacuum Devices. The purpose of the committee is to advise EDS on publication and conference policies and on trends in technology. Because of its geographic diversity, the committee has made use of teleconferencing and email to transact its business through virtual meetings. From the beginning, there was a strong sentiment within the committee to create an international conference focused exclusively on vacuum electronics. Dayton, formerly of NASA Glenn Research Center and now with Hughes Electron Dynamics in Torrance, CA, organized the Technical Committee and serves as its Chair. Dayton will also serve as the General Chair of IVEC 2000. Meeting Arrangements for IVEC 2000 are being managed by Ralph Nadel of Palisades Institute for Research Services. Francesco Emma, of ESA ESTEC in Noordwijk, The Netherlands, will serve as General Chair in 2001. The other members of the committee, their affiliations and their roles within IVEC follows:

Ivor Brodie, SRI International, Menlo Park, CA, USA
B. N. Basu, Banaras Hindu University, Varanasi, India
Richard G. Carter, Lancaster University, Lancaster, United Kingdom
Jon A. Christensen, Hughes Electron Dynamics, Torrance, CA, USA, Local Organizing Chair
Kwo Ray Chu, National Tsing Hua University, Hsinchu, Taiwan
Georges J. Faillon, Thomson Tubes Electroniques, Velizy, France
Takao Kageyama, NEC Corporation, Kanagawa, Japan
Gunter Kornfeld, TTE GmbH, Ulm, Germany
Carol L. Kory, NASA Glenn/Analex, Cleveland, OH, USA, Publicity Chair
Sheng Gang Liu, University of Electronic Science and Technology, Chengdu, China
Neville C. Luhmann, Jr., University of California, Davis, CA, USA
W. Devereux Palmer, Microelectronics Center of North Carolina, Research Triangle Park, NC, USA, Publications Chair
Gun-Sik Park, Seoul National University, Seoul, Korea
Robert K. Parker, Naval Research Laboratory, Washington, DC, USA, Finance Committee Chair
Vladimir Savvin, Moscow State University, Moscow, Russia
Armand Staprans, Communications and Power Industries, Palo Alto, CA, USA
Richard B. True, Litton Systems Inc., San Carlos, CA, USA, Technical Program Chair


James A. Dayton, Jr.
Hughes Electron Dynamic Division
Torrance, CA

2000 International Conference on Indium Phosphide and Related Materials (IPRM)

The IEEE International Conference on Indium Phosphide and Related Materials (IPRM) will be held 14 - 18 May 2000 in Williamsburg, VA. IPRM will continue its tradition of highlighting a wide variety of important developments in InP-related materials, devices, processing, and system applications. The venue for the millennial IPRM meeting is Williamsburg, the culturally and historically rich Tidewater region of eastern Virginia.

An important feature of this meeting will be the participation of many of the leading purveyors of equipment, materials, and substrates showcasing their latest products. As has been the tradition, several of the important conference events will be sponsored or hosted by these companies. A conference banquet is being organized which promises to be a unique and entertaining Y2K event that you will not want to miss.

The following five topical areas comprise the scope of the Conference and papers:

• Optoelectronics - Sessions will highlight new levels of performance improvements in traditional edge-emitting and VCSEL lasers. Advances in optical modulators and amplifiers, waveguide-based devices, quantum structures, photodetectors, photonic and optoelectronic integration of devices, and high-speed receivers are also solicited. New devices for optical switching, networking and signal processing are of interest as well as papers describing the properties and performance of photonics-bandgap structures for enhanced optical signal processing.

• Electron Devices - Papers are solicited that show marked improvements in HEMT, PHEMT, JFET, HFET, HBT, or RTD device and circuit performance. Topics include low-noise, low-voltage, power, and switching characteristics as well as scaling issues and the development of (continued on page 6)
IPRM (continued from page 5)

ment of integration techniques employing HEMTs, HBTs, RTDs, etc. Contributions describing unique electron-device concepts based on tunneling, quantum-confinement, mesoscopic, or single-electron phenomena are encouraged.

• Epitaxy - Sessions will deal with advances in growth methods, the understanding of epitaxial and heteroepitaxial growth processes, and selective-area growth. Topics related to the growth of low-dimensional structures including quantum dots are also encouraged. Papers describing growth and characterization of lattice-mismatched heteroepitaxial materials, and other InP-based and related materials, e.g. TlInGaP, GaInNAs, InGaAsSb are of interest. Sessions will also focus on methods of monitoring, self-assembly processes, and growth-mode control.

• Processing and Materials Integration - Sessions will highlight advances in etching, lithography, metallization, dielectrics, and planarization, as well as wafer-bonding, compliant-substrate and transferred-substrate techniques. Topics include Schottky and ohmic contacts, low-damage deposition processes, passivation, and reliability issues. Papers are also solicited describing innovations in nanostructure fabrication techniques for realization of arrays of quantum wires and boxes, harmonized processing for integration of heterogeneous devices, in-situ processing, and novel selective etching methods.

• Characterization and Bulk Materials - Papers will focus on novel methods and new results on the characterization of materials (both bulk and epitaxial) and devices as well as in-situ control of processing steps with emphasis on quality control and reproducibility. Sessions will also focus on advances in bulk crystal growth technology, new characterization methods for impurity identification, improvements in homogeneity and purity in crystals, and wafer annealing are of interest.

The IRPM will also offer three Short Courses:

• Integration of Dissimilar Materials, Theresa M ayer, Penn State University
• InP-Based Electronics and Systems Insertions, Dwight C. Streit, TRW
• Recent Developments in InP-based Laser Diodes, Gary Wicks, University of Rochester

The IEEE Lasers and Electro-Optics Society (LEOS) and IEEE Electron Devices Society (EDS) are the sponsors of the conference. For additional conference program and registration information, please view our website at: http://www.ieee.org/leos or contact IEEE LEOS at: TEL: 732-562-3898; FAX: 732-562-8434; EMAIL: s.blodgett@ieee.org.

W endy Rochelle
IEEE LEOS Executive Office
Piscataway, NJ

Summary (continued from page 2)

Status reports concerning the MTT, ED, AP, CAS, CPMT, SSC, LEO and NPS societies were then given by their respective representatives. The morning session concluded with a presentation by Mike Lightner on the visions and goals of IEEE electronic products. He capitalized the former under the categories “publish once, render many”, added value, and continuity, while stating the IEEE goals of putting all products on-line.

The afternoon opened with reports by chapter representatives concerning IEEE and society memberships. The morning session concluded with a presentation by Mike Lightner on the visions and goals of IEEE electronic products. He emphasized the former under the categories “publish once, render many”, added value, and continuity, while stating the IEEE goals of putting all products on-line.

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Report of the IEEE EDS Meetings Committee

James T. Clemens
Meetings Committee Chair

Technical meetings are a key element in the continuing education and career development of the members of the IEEE. Thus, during the Spring of 1999, the Meetings Committee was restructured to align its membership with the activities that the committee is chartered to perform in order to support its mission and to improve its operational efficiency.

The Meetings Committee focuses on several key items, including: the technical, administrative and financial quality of our sponsored meetings; supporting the EDS efforts in globalization; and ensuring that sponsored meetings adhere to the required IEEE accounting practices of a non-profit organization. Additionally, the IEEE is a major publisher of technical material, and IEEE sponsored meetings coordinate the publication of their proceedings with the IEEE Book Broker Program. This Program supports a meeting’s proceedings by fulfilling individual “after conference” sales requests and also the dissemination of conference proceedings to many libraries throughout the world.

The EDS is a sound, healthy society with more than 12,000 members and, as such, we are constantly being requested to provide either cooperation, technical co-sponsorship, or sponsorship/co-sponsorship support to both newly proposed meetings and existing meetings. At present, the EDS has sponsorship/co-sponsorship of 34 meetings, technical co-sponsorship of 81 meetings and co-operation support of 11 meetings.

With respect to the issue of generating new meetings, whether they are small workshops or major conferences, the various EDS technical committees and the membership of the EDS, in general, are VERY creative in this effort. The science and technology of electron devices is growing at a rapid rate. As a result, the EDS is constantly being requested for various types of new sponsorships. During the last year we have handled 12 requests for new sponsorship.

With respect to new sponsorship, the first function that the Meetings Committee performs is to determine whether the subject matter of a new meeting is generally consistent with the field of interest of the EDS. Then formal sponsorship is voted upon by the membership of the Administrative Committee (AdCom).

Once sponsorship is granted, it is the responsibility of the Meetings Committee to provide the many types of support requested and/or required by the meeting organizers. These include administrative programs, budget review, financial advances, publicity and various other forms of logistical support and recommendations. During the meeting, there is coordination with the Membership Committee. And finally, at the close of the conference, the Meetings Committee helps with the completion of the IEEE financial reports.

While many of these activities may seem rather administrative, the Meetings Committee must deal with major issues, which at times, we have either little or no control of. For example, the EDS was a technical co-sponsor for the 1999 International Conference on Microelectronics (MIEL), which was scheduled to be held in October in Nis, Yugoslavia. Unfortunately, military action destroyed the city and the meeting had to be cancelled. However, it was decided that the MIEL proceedings would be published and handled by the Book Broker Program.

In other cases, the Committee has had to face the issue of “sunsetting” meetings that have lost their vitality and attendance. This is difficult when the volunteer organizers have been successful for many years, but the superhighway of technology evolution has left their meeting on the less traveled side road. And finally, the Meetings Committee, at times, must mediate major scheduling and conflicting issues to other technical entities. It is these activities that challenge the talents and skills of the Meetings Committee. In fact, there is never a dull moment.

Every year, the Meetings Committee holds its own workshop, in conjunction with the Winter AdCom Meeting, where EDS sponsored meeting organizers gather together and discuss evolving “best practices” and unique occurrences. By doing so, we are able to continuously improve the quality of our Meetings Committee activities, our sponsored technical meetings and our educational efforts for the EDS membership.

In addition to myself, the Meetings Committee consists of Lucian Kasprzak, W. Dexter Johnston, Amanda Papasso, and Wlliam Van Der Vort. Their extraordinary efforts enable the Meetings Committee to fulfill its vital role within the EDS.

James T. Clemens
Meetings Committee Chair

Revamped EDS Home Page!

The EDS Home Page has recently been totally revamped, i.e., enhanced content, new format and style, numerous links and the look and feel of the IEEE Home Page. The new web pages were created using the IEEE templates and are compliant with all IEEE design regulations.

Please check out the enhanced/new look EDS site at: http://www.ieee.org/eds.

Please let Carrie Lin (c.lin@ieee.org) of the EDS Executive Office know of any suggestions you may have for additional information and/or links you would like to see.

January 2000 IEEE Electron Devices Society Newsletter
The Compound Semiconductor Devices and Circuits Technical Committee (CSDCTC) was formed in early 1998 to provide a global forum on devices and circuits containing compound semiconductors. It thereby provides additional benefits to EDS members interested in exchanging knowledge about this rapidly developing field. The CSDCTC seeks answers to questions like: What are the exciting new technologies? Which of those technologies will enable new applications? Where are the new markets? Who are the players today and tomorrow? and W hat is the appropriate role for the EDS and other IEEE societies.

To answer such questions as those above, the CSDCTC acts as liaison to technically-related societies such as LEOS and M TTS; identifies “hot” technical areas; considers existing and new technology roadmaps; and works to insure that EDS has appropriate coverage of compound semiconductors in its publications, conferences, and workshops.

This year the CSDCTC members discussed the three main trends that together offer challenging technical opportunities for compound semiconductors. These trends are: merging digital audio, video, and other multimedia forms with digital data at the device and networks level; that is the digitization of everything; converging networks to seamless and packet switched digital architectures; and demanding more and more bandwidth due to the digitization of everything and to adding more and more subscribers who use multimedia forms and dislike latency.

Considering such trends, we identified “hot” technical areas that have the potential for commercial significance. The areas of great interest include: heterojunction bipolar transistors (HBTs) for wireless communications and perhaps for advanced analog-to-digital converters (ADCs) if suitably high count circuits can be fabricated; quantum dot lasers that emit in the blue and blue-green; millimeter wave circuits for intelligent cruise control in cars, trucks, and buses; high power and high temperature SiC and GaN devices; and magnetic semiconductors or spintronics.

We also discussed candidate technologies that are beginning to mature and for which consensus based planning or technology roadmaps would enable more competitive products for the marketplace. Such frequently cited technologies are very high frequency III-V and SiGe HBTs and driver amplifiers operating at 3V for optical modulators at 10 Gbps and 40 Gbps.

We established a joint WWW site with the Optoelectronics Devices Technical Committee on a server provided by the Inter-University Research Institute’s COBRA (Communication Technology: Basic Research and Applications), Eindhoven University of Technology, The Netherlands. CSDCTC’s URL is http://www.cobra.tue.nl/eds/compound-semiconductors.html. The 11 members of the CSDCTC, most of whom are also members of either LEOS or MTTs, welcome your comments and suggestions by EMAIL: hs.bennett@ieee.org.

Herbert S. Bennett
National Institute of Standards and Technology Gaithersburg, MD

First EDS Region 9 Chapters Meeting

The first Electron Devices Society Region 9 Chapters Meeting was held on September 5, 1999 at hotel El Ejecutivo, Mexico D.F. The meeting was attended by the chairs of 5 of the 6 chapters in the region, Paul K. Yu representing EDS AdCom and Krishna Shenai as the partner of the EDS chapters in Mexico and Brazil. Although the chair of the joint AP/ED/MMT Rio de Janeiro Chapter did not attend, representatives from Brazil, Ines Pereyra and Marcelo Paez, were present and expressed their intention to start a new chapter at the University of Sao Paulo.

The meeting started with a presentation by Dr. Arturo Escobosa, Head of the Department of Electrical Engineering at the Center of Research and Advanced Studies (CINVESTAV), followed by Dr. Alfredo Reyes, Head of the Section of Solid State Electronics, (SEES). They welcomed attendees and explained main activities of the Institution where the host chapter is located. Afterwards, Yu and Shenai made the explanation of the various resources and services available to EDS chapters and activities of the partner.

The chairs from Cuba, Maria M. Sanchez, from Venezuela, Francisco Garcia, from the two student chapters in Mexico, Salomon Ledezma and Jose Luis Dominguez, and Magali Estrada from the Mexico Chapter, explained the different activities developed by their respective chapters and discussed problems that must be solved in the region to increase membership and activities. Of special interest among participants was the presentation by Salomon Ledezma concerning the experience of postgraduate students of CINVESTAV as a student chapter at On Semiconductor (formerly Motorola). A special report of these activities will be prepared for publication in the EDS Newsletter. The Cuba chapter reported...
their support to the organization of the International Optoelectronic Conference held in Mexico. The three chapters in Mexico, in addition to videos and distinguished lecturers, are organizing a yearly (this was the third issue) workshop on Simulation and Characterization Techniques that has become a way of exchanging experience among specialists in Region 9 and North America working in this field. The Region Meeting was organized the day before this Workshop started. All chairs expressed their intention to strengthen relations among chapters in the region, and decided to organize a Region 9 meeting at least biennially.

Other issues discussed were the biennial organization of an Electron Devices International Conference in Region 9. The attendees asked for the cooperation of EDS and encouraged ED members from the U.S. to actively participate in it, as well as look for industrial participation in Region 9 activities. Chapters will encourage the submission of more IEEE papers from our region and suggested the nomination of an editor from the region for Transactions on Electron Devices. They will also suggest experienced members to present their nomination for Senior members. Among the problems to be solved for Region 9, the most important deals with the membership inscription fee, which is the same as for USA members and is therefore too high when compared to salaries in the region. Until this is solved, it appears difficult to increase the membership in the region. Chairs were asked to contact their partners, since a number of partners have never gotten in touch with their chapters.

Attendees were quite satisfied with the meeting and considered it very fruitful and a good start for future work in the region, expressing their congratulations to the organizers. The work done by the Mexico Chapter was recognized, not only for its internal activities, but also for its effort to join the technical activities of chapters in the region. The Mexico chapter was recommended for proposition as chapter of the year.

Magali Estrada
SEES, CIN VESTAV-IPN
Mexico D.F.

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The IEEE Transactions on Semiconductor Manufacturing (TSM) Best Paper Award is presented annually to the authors of that paper considered by the TSM Editorial Board to be the most outstanding paper published during the year. The Award is based on the accuracy, originality, and importance of the technical content, as well as the quality and readability of the manuscript. The Best Paper is also based on the potential or immediate impact that this work could have on the semiconductor manufacturing industry. This award, presented at the annual Advanced Semiconductor Manufacturing Conference, recognizes the ongoing partnership of this conference and the IEEE.

The Editorial Board is pleased to announce that the paper entitled "A Novel In-Situ Monitoring Technique for Reactive Ion Etching Using a Surface Micromachined Sensor" by M. Baker, F. Williams, and G. May has been recognized as the best paper published in the 1998 Transactions. This paper, which appeared in the May issue, has been selected because it describes a unique and innovative technique for monitoring film thickness in reactive ion etching (RIE) by incorporating a micromachined sensor. The sensor was tested in an RIE system and was shown to offer high resolution, potentially permitting accurate in-situ monitoring of etch rate or uniformity at a nominal cost.

Michael D. Baker
received a B.S. degree in electrical engineering from Florida Agricultural and Mechanical University, Tallahassee, in 1990, and M.S. and Ph.D. degrees in electrical engineering from the Georgia Institute of Technology, Atlanta, in 1992 and 1996, respectively. He is currently a Hardware Design Engineer in the Ink Jet Supplies Business Unit, Advanced

(continued on page 10)
Best Papers (continued from page 9)

Research Lab, Hewlett Packard, Corvallis, OR. He has worked at several divisions of Honeywell, including Space and Strategic Defense, Sensors Research Center, and Commercial Flights. He has also conducted research at the University of Michigan, Ann Arbor, in electromagnetics. His research interests include in-situ monitoring techniques for plasma-based processes and microsensors.

Frances R. Williams (S’94) received B.S. and M.S. degrees in electrical engineering from the North Carolina Agricultural and Technical State University, Greensboro, in 1994 and 1996, respectively. She is currently pursuing a Ph.D degree at the School of Electrical and Computer Engineering, Georgia Institute of Technology, Atlanta, where she is an Alfred P. Sloan Foundation Fellow. She is a National Science Foundation and an Office of Naval Research Graduate Fellow. She has interned at Fermi National Accelerator Laboratory, Batavia, IL, as well as several divisions of NASA Goddard Space Flight Center, Greenbelt, M.D. Her research interests include microelectronics, acoustic sensors, and in-situ monitoring techniques of plasma-based processes.

Gary S. May (S’85-M’90-SM’97) received a B.S. degree in electrical engineering from the Georgia Institute of Technology, Atlanta, in 1985 and M.S. and Ph.D degrees in electrical engineering and computer science from the University of California at Berkeley in 1987 and 1991, respectively. He is currently an Associate Professor at the School of Electrical and Computer Engineering and Microelectronics Research Center at the Georgia Institute of Technology. He has worked as a Member of Technical Staff at AT&T Bell Laboratories, Murray Hill, NJ. His research is in the field of computer-aided manufacturing of integrated circuits, and his interests include semiconductor process and equipment modeling, process simulation and control, automated process and equipment design, and yield modeling. Dr. May is a National Science Foundation “National Young Investigator” and is Editor-in-Chief of IEEE Transactions on Semiconductor Manufacturing. He was a National Science Foundation and an AT&T Bell Laboratories graduate fellow. He is Chairperson of the National Advisory Board of the National Society of Black Engineers (NSBE).

CD ROM Packages Available to EDS Members

The EDS CD ROM Package includes all issues for a given year of the Electron Device Letters (EDL) and Transactions on Electron Devices (TED), as well as the proceedings of the given year of the International Electron Devices Meeting (IEDM). The CDs have an easy to use interface and are searchable by author, title and keyword. All materials were published using Adobe Acrobat Technology. Included on the CD ROM are versions of Acrobat Reader for Microsoft Windows, Apple Macintosh and UNIX.

Currently, EDS has three CD ROMs available to EDS members. Each is available for US $25.00 (US $19.00 for students).

- 1997 EDS CD ROM Package
- 1998 EDS CD ROM Package
- 1999 EDS CD ROM Package

(expected shipping date is May 2000)

If you would like to receive an order form for any of these products, please contact the EDS Executive Office (contact information provided on page 2).

Announcement of the Availability of IEEE Fellow Kits

The Fellow nomination process is relatively straightforward, but requires some forethought and planning preceding the 15 March 2000 deadline. Both a nominator and at least five, but no more than eight references from current Fellows are required.

Fellow kits can be requested in hard copy format or downloaded from the Web.

Fax: (732) 981-9019; E-MAIL: fellow-kit@ieee.org; URL: http://www.ieee.org/about/awards/table1.htm

EDS ‘Permanent’ Membership Option

EDS members have available the option of making a one-time payment of $25 to become a ‘permanent’ member of EDS. The only requirement to become a permanent EDS member (besides the $25 fee) is to maintain your IEEE membership.

Current IEEE and EDS members are able to request this option via their 2000 IEEE membership renewal bill. IEEE members who are not members of EDS can also use their 2000 renewal bill to request permanent EDS membership. In addition, non-members of the IEEE are also able to request this option by completing the 2000 IEEE/EDS membership application form. We encourage you to take advantage of this EDS offering and benefit. The option is not available to IEEE student or EDS affiliate members.
USA, Canada and Latin America (Regions 1-6, 7 & 9)

Report of the International Workshop on Simulation and Characterization Technique
by Magali Estrada

Simulation and characterization techniques each day become more important tools in semiconductor physics and technology research and development. Today it is not conceivable to develop a technological process or a new device, or even study a physical structure without them. For these reasons, these matters have been introduced as part of the graduate and undergraduate curriculum in all prestigious academic institutions.

Academic institutions in Mexico and other Latin American countries have also introduced these techniques in their curricula and now have the possibility of analyzing results and discussing perspective work in this field. In Mexico, the National Council for Science and Technology (CONACYT) has been supporting the introduction of these techniques in universities as well as in research and development projects.

During the last three years, the Center of Research and Development Studies of the National Polytechnic Institute (CINVESTAV-IPN), in Mexico City has organized the International Workshop on Simulation and Characterization Technique to provide a forum to present and discuss activities, ideas and results. This year we invited 4 lecturers, Dr. Ines Pereyra from the University of Sao Paulo, Brazil, Dr. Adelmo Ortiz from the University Simon Bolivar in Venezuela, Dr. Jiun Liou from the University of Central Florida and Dr. Krishna Shenai from the University of Illinois at Chicago. As it has become standard practice for our workshops, all contributions have been gathered in a digest which contains the main aspects in which academia and researchers are working to apply and develop simulation and characterization techniques in the semiconductor field. The number of contributions has increased from year to year both in number and in quality as a result of the development this field of research is achieving. The panel in this occasion dealt with the state of the art of simulation and characterization techniques in Latin America and it was really interesting to notice the results obtained in just a few years.

This third Workshop was developed quite successfully and gave us again the possibility to bring together researchers and students from different institutions and to strengthen international collaboration in this field of research. We hope this Workshop will continue in the next years, increasing the number of participants as well as inviting lecturers and receiving contributions from other countries. It is also a proposal to increase the participation of students.

We want to thank the support given by the IEEE Electron Devices Society (EDS), CONACYT, and the Section of Solid State Electronics at CINVESTAV for the organization of this Workshop. We also want to thank the Technical Committee for its work in selecting the papers for presentation. Thanks to the speakers and participants for their excellent presentations and interest.

International Conference on Microelectronics and Packaging
by Nelson Braga

The XV SBMicro - International Conference on Microelectronics and Packaging will be held at the Hotel Tropical in Manaus, Brazil, in the heart of the Rain Forest, September 18 - 23, 2000. This conference offers a unique blend of microelectronics and packaging and serves as an instrument to gather scientists working on both topics. The multi-disciplinary nature of SBMmicro conferences is intended to emphasize the interactions among processing and packaging technologies, devices, CAD and circuit design, through a variety of formats, such as oral presentations, poster sessions, exhibits, panel discussions, and tutorial sessions. The XV SBMmicro Conference will maintain its tradition to offer two-day tutorial courses taught by prominent scientists from around the world who will also present their invited papers at the conference itself.


—— Mark Weichold, Editor

Europe, Middle East & Africa (Region 8)

MTT/ED/AP/LEO UK & RI Chapter Says Thank You to Terry Oxley by Ali Rezazadeh

The MTT/ED/AP/LEO UK & RI Chapter meeting held at Leeds University on Thursday, 16 September 1999 was an appropriate occasion for a presentation to Terry Oxley, a Life Member of IEEE. Terry was there to receive an official vote of thanks from all IEEE fellow members on behalf of the association and was presented with a beautiful crystal glass bowl. The meeting was chaired by Dr. Ali Rezazadeh (King’s College London), the Chair of the UK and Northern Ireland Chapter, and the vote of thanks given by Professor Carson Stewart of the University of Belfast, Northern Ireland, the Secretary of the Chapter.

Terry Oxley’s contribution to the Chapter, industry and education is well recognized internationally. He has received many awards during a lifetime of dedicated service, including Her Majesty’s Silver Jubilee Medal in 1977 for his contribution to advancements to microwave components, and in 1989, the GEC Nelson Gold Medal for Company technical achievement. His long career started during the World War II, when for four years he served as an HO (Hostilities Only) Electrical Artificer, after which, in 1946, he joined GEC Hirst Research Centre, (HRC) retiring in 1988 after 42 years of service. Terry’s record at HRC was one

Attendees of the International Workshop on Simulation and Characterization Technique.
of outstanding achievement in Research and Development in the field of microwave/millimeter-wave solid state devices and circuits, as he progressed through the HRC management structure to the position of Microwave Research Coordinator for GEC Research Ltd., reporting to the Managing Director. Some of his many professional activities over the past eleven years since his retirement from GEC have included: Chair (then member) of the MTT/ED/AP/LEO UK&RI Chapter Administrative Committee; Editor for the EDS Newsletter; European liaison for the MTT-S IMS & AdCom; and TPC service for the Military Microwaves and Microwave & RF Conference events. During this period he received the IEEE Region 8 Section Volunteer Award and the MTT-S Meritorious Service Award. Terry was also one of the founders of the successful W workshop, EDMO (Electron Devices for Microwave & Optoelectronics).

We thank you, Terry, for an outstanding contribution to the industry, Engineering profession and Education, and wish you well in your second retirement.

MTT/ED/AP/LEO UK&RI Joint Chapter
by Ali Rezazadeh

The highlights for our Chapter are as follows:

• The Chapter, in cooperation with The University of Surrey and technical cosponsorship by the IEE, organized a W workshop 5-6 July 1999 at The University of Surrey, UK on ”Non-linear Device Characterization and Use in RFIC and MMC Power Amplifier Design”. The meeting was very successful and about 55 delegates attended this meeting.

• The ”IEEE 1999 Fourth Postgraduate Student High Frequency W workshop” was held 16-17 September 1999 at the University of Leeds, UK and the Chairman was Dr. Stavros Iezekiel of University of Leeds. In the evening of 16th September the W workshop dinner was arranged and many postgraduate students and other delegates had an enjoyable, friendly gathering. The main W workshop was on 17 September and 15 oral and 11 poster papers were presented. An IEEE proceedings was prepared and this is now available via the IEEE (IEEE Catalog Number: 99TH8409; ISBN: 0-7803-5577-6 Softbound Edition; Library of Congress: 99-61881). My sincere congratulations must go to the W workshop Chairman, Dr. Iezekiel, who had done an excellent job of organizing such a successful event.

• An afternoon lecture was jointly organized with the UK&RI Communications Society Chapter on Monday 20 September. In this event, Prof. Fred Harris, San Diego State University, USA, gave a popular seminar on ”DSP Techniques for Digital Radio Design” at King’s College London, UK.

• The ”7th IEEE International Workshop on Electron Devices for Microwave and Optoelectronic Applications - EDMO ’99”, jointly organized by the Chapter and King College London, and with technical co-sponsorship by EDS, is planned for 22-23 November 1999 at King’s College London. Details of this event are available from the Chapter Chairman, Ali Reza-zadeh. EDMO’99 web: www.kcl.ac.uk/eleceng/edmo99.

• An evening lecture is planned for the 14th December 1999 at King’s College London, on ”Passive Radiometry”, by Roger Appley.

For further information, please contact the Chapter Chair: Dr. Ali A Rezazadeh, Department of Electronic Engineering, King’s College London, Strand, London WC2R 2LS, UK. TEL/FAX: +44 171 848 2879; EMAIL: ali.rezazadeh@kcl.ac.uk.

ED /MTT Egypt Section
Ibrahim Salem

The ED/MTT Egypt Chapter organized a W workshop on Teaching Photonics at the Egyptian Faculties and Institutes on May 18, 1999. This workshop was held at the National Institute of Laser Enhanced Science, Cairo University, Giza. Thirteen papers were presented and the authors were from the following Universities: Cairo; Alexandria; Ain Shams; Menoufia; Zagazig; Higher Technological Institute; Ramadan 10th City; and the National Telecommunication Institute. The workshop record has an IEEE catalog Number: 99EX285. The second such workshop will be held on Oct 12th, 2000.

— Gady Golan, Editor

ED Romania Chapter
by Gheorghe Brezeanu

During the last several months the ED Romania Chapter’s activities included some interesting events, the main of which was the CAS’99 conference. In May 1999, the annual professional student contest ”Tudor Tanasescu” was organized at ”Politehnica” University, Bucharest. A total of 57 undergraduate students from all Romanian technical universities took part in two sections of this event: Analog Integrated Circuits and Signals as well as Circuits and Systems. Ten students were awarded with PC mainboards and peripherals, technical books and magazines, IEEE/EDS membership vouchers and cash. The contest was sponsored by IEEE EDS and Romanian microelectronics firms. Because of the strong student impact and the significant number of chapter members involved in the contest preparation, we consider the ”Tudor Tanasescu” professional contest as the best practice of our chapter.

In July, a videotape projection was organized at the Microtechnology Institute in Bucharest. The 1998 IEDM tape ”Next Generation TCAD: Models and Methods” from the EDS lending library was shown to an audience of 37, including 20 chapter members.

The 22nd edition of the International Semiconductor Conference (CAS’99) was held in Sinaia, Romania, during October 5-9, 1999. The conference, sponsored by EDS, included 125 papers delivered in 2 plenary and 15 regular sessions. A special student paper session was also included in the program. This meeting brought together more than 200 scientists and technologists from all over the world to discuss the most recent developments and future directions in the field of microelectronics. During the years, the CAS has established itself as an important Conference of Eastern and Central Europe for engineers and researchers both in academia and industry.

In conjunction with CAS’99, a W workshop entitled ”MOS Controlled Power
MTT/ED/AP/CPMT West Ukraine Chapter

by Mykhailo Andriychuk

Our joint chapter, with a total of 35 members (including 10 student members), organized five professional meetings in the first three quarters of 1999. Our main activity was the 4th International Seminar / Workshop “Direct and Inverse Problems of Electromagnetic and Acoustic Wave Theory (DIPED-99)”, which was organized by our chapter together with the MTT / ED / AP / EMC Republic of Georgia Chapter September 20-23 in Lviv, Ukraine. The Seminar / Workshop was dedicated to the 80th Anniversary of Professor B.Z. Katsnelenbaum. Thirty-six papers from Ukraine, Georgia, Russia, USA, Canada, Japan, and Poland were included in the program. The Workshop proceedings were published and included in the IEEE Book Broker Program. The Workshop was organized with technical co-sponsorship of EDS, and financial and technical support of the MTT, ED, AP, CPMT Societies, as well as the Region 8 Chapter Coordination Committee.

The chapter also participated in the organization of the Conference "Experience and Application of CAD Systems in Microelectronics" (CADSM '99), held in February 1999 in Slavsko, Ukraine. Owing to the efforts of the chapter and with the support of Dr. Charles Turner, Region 8 Activities Vice-Chair, the Lviv Scientific Library has been included in the IEEE Library Project. The library obtains IEEE journals which are actively used by our members, as well as by the scientific and engineering community and students of the region.

MTT/ED/AP/CPMT SSC Nizhny Novgorod Chapter

by Yuri Belov

Our joint chapter has organized several successful events during the previous period. These include chapter patronage of the regular Seminar on the Microwaves and Electrodynamics of the Nizhny Novgorod State Technical University and co-sponsorship of Summer Students Space School held near Nizhny Novgorod, from July 15 to August 3, 1999. Especially interesting for EDS Newsletter readers would be the following two activities.

This year two faculties of Nizhny Novgorod State Technical University announced a contest of Master of Science Dissertations. Thus, we raised the level of the IEEE Nizhny Novgorod Chapter prize in comparison with previous years and planned a US $100 prize for the awardees. Two MA theses were selected ("Development of facility for phone stations interconnection control", by A.Zakharov; and "Development and investigation of filtering algorithm for speech recognizing", by K. N. Iikashov). The new Masters of Science candidates received their prizes together with MS diplomas.

The second activity was the International Workshop, "Probe Microscopy'99", which was held 9-12 March 1999 at the Institute for Physics of Microstructures RAS, Nizhny Novgorod. Organization of the Workshop was supported by the Russian Foundation for Basic Research, the Ministry for Science and the Ministry for Education of the Russian Federation. The Workshop was organized with the aim of disseminating the results of the leading research groups and exchanging experience in the solid surface research by means of scanning probe microscopes. The scope of the meeting included presentations in the following areas: scanning tunneling microscopy and spectroscopy, probe microscopes as applied to development and the study of nanosstructures properties, atomic-force microscopy, optical near-field microscopy, physics of microcontacts, emission electrons, original microscope designs and novel methods of surface research. More detailed information is available at: www.ipm.sci-nnov.ru and www.nanoworld.org/russian/sem_conf.htm.

ED Novosibirsk State Technical University Student Branch Chapter

by Alexander Girdchin

The IEEE Student Branch in the Novosibirsk State Technical University was founded on March 8, 1999. It is the first IEEE Student Branch in Novosibirsk and the second IEEE Student Branch in Russia. Currently we have 28 student members and two Student Branch Chapters: ED and SSC. The Branch has had a growth in membership during the summer 1999 - eight new students have joined IEEE and we have new applications.

One of our students took part in the 3rd Korean-Russian Symposium KO RUS'99 in June 1999 and five members took part in the 2nd IEEE-Russia Conference “1999 High Power Microwave Electronics: Measurements, Identification, Applications” (MIA-M.E’99). In 2000, we plan to hold the 1st Siberian IEEE-Russia Student Workshop on Electron Devices and Materials EDM’2000 (23-26 September, 2000). For this Workshop, we plan to invite some speakers from the EDS Distinguished Lecturers Program. We have good cooperation with the joint IEEE ED / MTT / CPMT / COM / SSC Novosibirsk Chapter. The Workshop will be organized with the support of this chapter and in conjunction with the 5th International Conference on Actual Problems of Electron Instrument Engineering (APEIE-2000).

Up to October 1999, we have held three student technical meetings (one each month during the semester) and we plan to hold another three meetings by the end of 1999. We presented the 1993 IEDM Videotape Course in May 1999 and plan to extend this direction of our activity by borrowing more tapes from the EDS Videotape Library. During October-November, we plan to organize language courses for our student members to increase the English knowledge level of students. We have sent papers to the program “IEEE Student Branch Center of Excellence” and want to establish the first student Open Design Laboratory. We will continue to make all efforts to include our students into the scientific, educational and technological process worldwide and in this respect count on further precious help of IEEE EDS.

— Ninoslav Stojadinovic, Editor

Asia & Pacific (Region 10)

IEEE LEO / ED Victorian Chapter

— by Dalma Novak

A joint LEO / ED Chapter located in the IEEE Victorian Section of Australia, was formed in November 1998 with Dr. Dalma Novak as the incumbent chair. There are now two EDS Chapters in Australia with the original chapter located in Canberra, chaired by Professor Jagadish, initially representing all IEEE EDS members. The LEO / ED Victorian Chapter participated in the Workshop on Semiconductor Electronics organized by the LEO / ED Australia Chapter in March 1999. Recently, the Chapter held a video technical seminar on Trends in RF Devices for Wireless Applications. In November, 1999, Professor Paul Yu from the University of California, San Diego, will be giving a presentation for the Chapter in his capacity as an EDS Distinguished Lecturer.
ED/MTT India Chapter
by K.S. Chari

During July-September 99, the Chapter focused efforts on the STAR Program, encouraging more conferences, initiating a new membership drive, enlisting more volunteers for chapter efforts and completing the election process.

Through detailed interactions with neighboring states, the Chapter had identified Kurukshetra forming part of Haryana State as the venue for carrying out the STAR Program for the year 1999-2000. The Chapter has purposely launched the STAR Program outside the national capital to promote the awareness to this scheme and involve more regional beneficiaries. Preliminary screening identified three higher secondary schools, i.e., D.A.V. Public School, Aggarsain Public School and Maharana Pratap Public School at Kurukshetra. The teacher co-ordinators from these schools are Ms. Geetika Jasuja, Ms. Indu Sabharwal, Ms. Monica Gupta, Mrs. Kavita Mahajan and Mrs. Betty Gregory. As in previous years, the Chapter received overwhelming response to the STAR enrollment and a total of 40 female candidates drawn from 10th to 12th standard grades were finally selected. Ms. Anurekha Sharma from Electronic Science Department, Kurukshetra University, volunteered as the chapter local STAR coordinator.

The first STAR event was held on the 25th of September at Aggarsain Public School. STAR related videos obtained from the EDS lending library, i.e. Who are Engineers and Careers for Electrical Engineers and Scientists, etc., were screened to the STAR participants. The Chapter Chair addressed the meeting and clarified many queries in detail. Mrs. P. Singh, Principal of the Aggarsain Public School, Mrs. A. Philip, Principal of the Maharana Pratap Public School and the STAR Teacher Coordinators attended this gathering. The Chapter Chair received substantial support from Prof. P. George, Head, Electronic Science Department at Kurukshetra University and Mrs. George for seeding the STAR activity at Kurukshetra.

Plans for the Chapter to support and co-sponsor various International/National workshops in ED/MTT areas were finalized. The Sixth International Conference and workshop on Electromagnetic Interference and Compatibility, is to be held in New Delhi during 28-2 December, 1999. The Tenth International Workshop on Physics of Semiconductor Devices (IW PSD-99) is to be held 14-18 December 1999. The Workshop on Millimeter Wave Components and National Conference on Communication (NCC-2000) are planned to be held in December 1999 and January 2000, respectively.

A special student membership drive was launched at Kurukshetra University, Indian Institute of Technology (Delhi) and the Department of Electronics (Delhi campuses). A total of 6 new EDS/MTT members were enrolled. Several strategies for further increase in student participation in Chapter activities and membership are identified and pursued.

The Chapter Chair and Secretary had a very useful meeting on Chapter efforts in India with the IEEE TAB Colloquia members on 19 and 20 September 1999. The TAB committee consisted of IEEE President Prof. Kenneth R. Laker, TAB Vice President Dr. Michael S. Adler, MD of Technical Activities Ms. Mary Ward-Callan, Chair of TAB Colloquia Dr. Peter W. W. Es Spencer and IEEE Manager of the Asia Pacific Operations Centre, Ms. Fanny Su Beh Nol. Chapter Executives discussed the best ways of drawing more active volunteers for the chapter efforts and restructuring the past office bearer and executive teams. From this exercise, the Chapter has elected fresh teams for the year 1999-2000.

For more information on Chapter activities, please contact Chapter Chair, Dr. K.S. Chari: TEL: 91-11-4361464; FAX: 91-11-4363082; E-MAIL: chari@xm.doe.ernet.in.

REL/CPMT/ED Chapter Singapore
by Dr. Ong Soon Huat

The Chapter Secretary, Mr. Y. C. Ng, represented the IEEE RU/CPMT/ED Singapore Chapter in the 3rd Biennial EDS Region 10 Chapters Meeting that was held on 13 June, 1999 in Kyoto, Japan. Ten of the 13 EDS Chapters from Region 10 were represented in Kyoto to share their chapters’ activities and exchange of ideas.

The 7th International Symposium on the Physical & Failure Analysis of Integrated Circuits (IPFA’99) was organized by the IEEE RU/CPMT/ED Singapore Chapter 5-7 July, 1999 at the Orchard Hotel, Singapore. The symposium drew 160 participants from 16 countries from Asia, Europe and America. There were 42 papers (three of which are invited papers) presented in the symposium from participants of 15 countries across Asia, Europe and America. The papers were selected by peer review from among more than 90 papers received. Along with the Symposium, four tutorials were conducted by experts in each area of failure analysis and reliability. The tutorials were attended by more than 120 participants.

The equipment exhibition arranged along with IPFA has attracted a number of personnel from industry.

The IEEE RU/CPMT/ED Singapore Chapter donated S$15,000 ($8,700 USD) to the National University of Singapore as an Endowment Fund. The interest generated from this Fund will be used to sponsor an annual Book Prize to the best student in the “Integrated Circuit Reliability Physics and Failure Analysis” course, offered at the Masters level at the University of Singapore. The book prize is set at S$300 plus one year IEEE membership fee. This award is an encouragement of academic excellence and professional development in the area of Integrated Circuit Reliability Physics and Failure Analysis, which is in line with the objectives of the Singapore RU/CPMT/ED Chapter. It will also be useful as a means of membership.
development in promoting awareness of IEEE and its activities. The "IEEE Singapore Reliability Book Prize Award" presentation was held on July 24th, 1999. Dr. SH Ong, the Chapter's Chairman, presented the check to Prof. Daniel Chan, Departmental Head for Electrical Engineering Department, National University of Singapore (see Picture). The invited guests at the presentation ceremony included Prof. Cary Yang, EDS Vice President.

For more information on Chapter activities, please contact the Chapter Chair, Dr. Ong Soon Huat. E-MAIL: soon.huatong@nsc.com.

— W.K. Choi, Editor

Report of the 7th International Workshop on Advanced LSIs and Devices

— by Kwyro Lee

The 7th International Workshop on Advanced LSIs and Devices, organized by The Institute of Electronics Engineers of Korea (IEEK), The Institute of Electronics, Information and Communications Engineers (IEICE) of Japan, and IEEE Electron Devices Society Tokyo Chapter and sponsored by Hyundai Electronics Industries, Samsung Electronics, Yang Electronic Systems, and Ansoft Korea, was held at Phoenix Park, Pyungchang, Korea, during July 22-24, 1999. This annual workshop started in 1993 to bring together the engineers and scientists in Korea and Japan to discuss the present and future LSI processing and device technologies and alternates between Korea and Japan every year. This year's topics were: i) 0.1 micron technologies, ii) memory devices and circuits, iii) silicon RF devices and circuits, iv) Ferroelectric technologies, and v) IP based design. This year, the IEEE ED Korea Chapter became involved as one of the supporting organizations as a counter part of the IEEE ED Tokyo Chapter.

At the workshop, 112 participants (90 Korean and 22 Japanese) registered, and 64 selected papers (49 from Korea and 15 from Japan) were presented, including 7 invited papers. The Conference Chairman was Dr. Hyung-Moo Park of ETRI, and the General Secretary was Prof. Kwang-Ho Kim at Dept. of Semiconductor Engineering, Cheongju Univ.

Next year, the conference will be held in Japan. For more information, contact Prof. Kwang-Ho Kim TEL: +82-431-229-8465; FAX: +82-431-229-8432; E-MAIL: khkim@alpha94.chongjiu.ac.kr.

Report of the 1999 International Conference on Simulation of Semiconductor Processes and Devices (SISPAD'99)

by Noriaki Nakayama

The 1999 International Conference on Simulation of Semiconductor Processes and Devices (SISPAD'99) (co-sponsored by the IEEE Electron Devices Society and the Japan Society of Applied Physics) was held at Kyoto Research Park, Kyoto, Japan, September 6-8, 1999. The purpose of the Conference was to provide an opportunity for the presentation and discussion of the latest topics in process, device and circuit modeling for Semiconductors. One hundred seventy-four people from 16 countries attended the Conference and 62 papers, selected from the 103 papers submitted, were presented. There were two features in the SISPAD'99: one was increased contributions from Europe; the other was the significant advance in the atomistic simulation, the three-dimensional grid generation and the gate tunneling simulation. SISPAD 2000 is scheduled to be held September 6-8, 2000 at Sheraton Seattle Hotel and Towers, Seattle, WA, USA. Further information can be obtained at http://www-tcad.stanford.edu/sispad2000.html.


— by Hisatsune Watanabe

The 1999 International Conference on Solid State Devices and Materials (SSDM 99), sponsored by The Japan Society of Applied Physics, was held September 21-24, 1999 at Nihon Toshi Center Kaikan, Japan. The purpose of this conference is to bring together scientists and engineers actively engaged in the forefront of solid-state devices and materials. From the 1999 conference, fifteen program-subcommittees have been established for covering circuit and system areas as well as device and materials areas. In addition, 3 short courses (in Japanese) were held on September 20. The number of participants of the conference was 666 from 19 countries and regions. The following 3 plenary papers were presented: "Japanese Management in an Era of Change" by Mr. J. Ushio (Chairman and CEO, Ushio Inc., Japan), "Interconnection Limits on XXI Century Giga-scale Integration (GSI)" by Prof. J.D. Mieudli (Georgia Inst. of Technology, USA), and "R&D Challenges and Chance in Today's Japan" by Dr. S. Ogura (Halo LSI Design & Device Technology Inc., USA). Forty-five invited papers, 240 contributed papers and 9 late news papers were presented at the conference. SSDM 2000 is scheduled to be held August 28-31, 2000, at Sendai International Center. A one day short course will be held prior to the conference, on August 27, 2000. Detailed information is available via E-MAIL ssdm@bcasj.or.jp or URL: http://ssdm.bcasj.or.jp/.

Attendees of SSDM ’99: Prof. J. Miendl (center, one of the plenary speakers of the conference, Prof. T. Ohmi (right, Chair of SSDM 2000).
Announcement from Tokyo Chapter

by Hisatsune Watanabe and Masao Fukuma

As usual, an annual Briefing Session for the 1998 IEDM was held in Tokyo on January 20, 1999. This year, five speakers were invited to deliver summary talks on highlights of the 1998 IEDM. Topics covered were Silicon Process and Wiring, Silicon Devices, Silicon Integrated Circuits and Sensors, Modeling and Simulation, and Compound Semiconductor and Quantum Devices. The number of participants was about 120, including non-EDS members. In addition to the briefing session, the Tokyo Chapter provides several activities both on technical and non-technical events. The Chapter technically supported several international meetings including the 1999 International Conference on Simulation of Semiconductor Process and Devices (SISPAD '99) held in Kyoto and the 1999 International Conference on Solid State Devices and Materials (SSDM '99) held in Tokyo, both sponsored by the Japan Society of Applied Physics and the IEEE Electron Devices Society. The Chapter also supports domestic workshops sponsored by the Institute of Electronics, Information and Communications Engineers. The workshops, which are held monthly, are organized by two technical groups of the Institute, the Silicon Devices and Materials and the Integrated Circuits and Devices groups. To increase the EDS Tokyo Chapter membership, a Japanese version of the EDS membership information brochures has been prepared. These brochures have been distributed at several meetings such as the 1998 IEDM and 1999 Symposia on VLSI Technology and VLSI Circuits.

Meeting with Singapore Chapter

by Hiroshi Iwai

A meeting between the Singapore Chapter and its partner was held at the Shangril Hotel 6:30 - 9:00 p.m. on July 6, 1999 in conjunction with the IPFA'99 (7th International Symposium on the Physical & Failure Analysis of Integrated Circuits) held in Singapore. This was the 2nd meeting; the previous one was held in January 1998. S.H. Ong (Chapter Chair), Y.C. Ng (Chapter Secretary), Y.S. Gan, K.L. Pey, Y.K. Swee, Bernard Chin, W.K. Chim, Y.C. Ng (Chapter Chair), and H. Iwai (chapter partner) attended the meeting. One of the major activities of the chapter is to organize two international conferences - IPFA and EPTC (Electronic Packaging Technology Conference). The chapter wants the conferences to be more international such that IPFA would move outside of Singapore every two years. As a first step, the chapter requested the partner to help invite more Far East distinguished speakers to the conferences and to Singapore in general. The partner promised the support. It was recommended to invite more foreign people to the program committee of the conferences to make them more international. Application for a special issue of the IEEE Transactions on Electron Devices for reliability was one of the desires of the chapter in the previous meeting held in 1998. It was agreed to prepare to apply a special issue of IEEE Transactions on Electron Devices for IPFA 2001. It was also agreed for the chapter to make an effort to increase the number of members by setting-up an IEEE registration desk at the Singapore conferences. The population of the Fellow and Senior members in the chapter is very small despite its relatively large number of members (more than 200). The chapter will make an effort to increase the Fellow and Senior members with their partners help. The meeting was held in a very friendly atmosphere and the discussions were fruitful.


The 11th International Photovoltaic Science and Engineering Conference was held in Sapporo, Hokkaido, Japan, on September 20-24, 1999. The conference, co-sponsored by the IEEE and the Japan Society of Applied Physics, brought together 705 scientists and engineers from 38 countries to discuss about recent scientific and technological developments.

At the opening ceremony, the PVSEC Award was given to Prof. Makoto Konagai (Tokyo Institute of Technology) and the PVSEC Special Award to Dr. Kazuo Inamori, founder of Kyocera Corp. The technical program was organized in 8 categories from fundamentals, crystalline Si, amorphous Si, CdTe & CIGS, modules & system components, terrestrial systems and national programs. Three hundred and ninety-one contributed papers and 62 invited papers were presented at oral and poster sessions, which are record numbers in the PVSEC history due to the recent growth of the photovoltaic market for residential applications.

The topics of the presented papers included: 24.7%-efficient, monocrystalline Si cells, stable Ga-doped Si CZ cells, multicrystalline cell technology, amorphous cell mass-production technology, 30.9% InGaP/InGaAs tandem cells on Ge substrates, 14.7% CuInGaSe mini-module, building integrated PV modules, inverters for AC modules, PV in urban environment and remote applications in Asian countries. Two workshops highlighted the conference, including the informal Workshop on Light Degradation of Minority-Carrier Lifetimes in Cz-Si Solar Cells and IEA Workshop on Value-added PV Systems.

The conference also included an Exhibition of commercial modules and systems as well as newly developed products. Two thousand seven hundred and fifty people visited the Exhibition to look at the advanced products displayed at 34 booths. The next conference will be held in Cheju Island, Korea, in June, 2001. For more information, please contact the General Chair, Dr. Jinsoo Song, Korean Institute of Energy Research, e-mail: pvjsong@sun330.kier.re.kr

— Hiroshi Iwai, Editor
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May 1 – 5, 2000, **T EUROPEAN PHOTO-VOLTAGE SOLAR ENERGY CONFERENCE & EXHIBITION**, Location: Scottish Exhibition & Conference Centre, Glasgow, Scotland, Contact: Bettina Kaisa, Tel: 49-89-720 1235, Fax: 49-89-720 1291, E-Mail: renewable@net.de, Deadline: Past Due, www: http://www.wip.tnt.de

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August 7 - 9, 2000 * IEE CORNELL CONFERENCE ON ADVANCED CONCEPTS IN HIGH SPEED SEMICONDUCTOR DEVICES AND CIRCUITS, Location: Cornell University, Ithaca, NY, Contact: Elke Schofield, Tel: (607) 253-3409, Fax:

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